

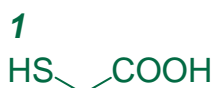
Scherzo SS-C18

100 x 3 mm

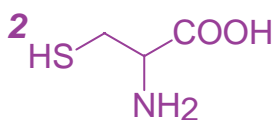
HPLC COLUMN APPLICATION

LC-MS: Components in permanent wave lotion

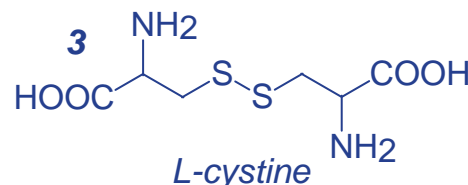
パーマ液成分の LC-MS 分析



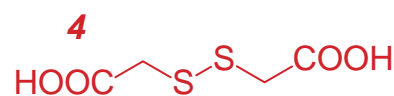
thioglycolic acid



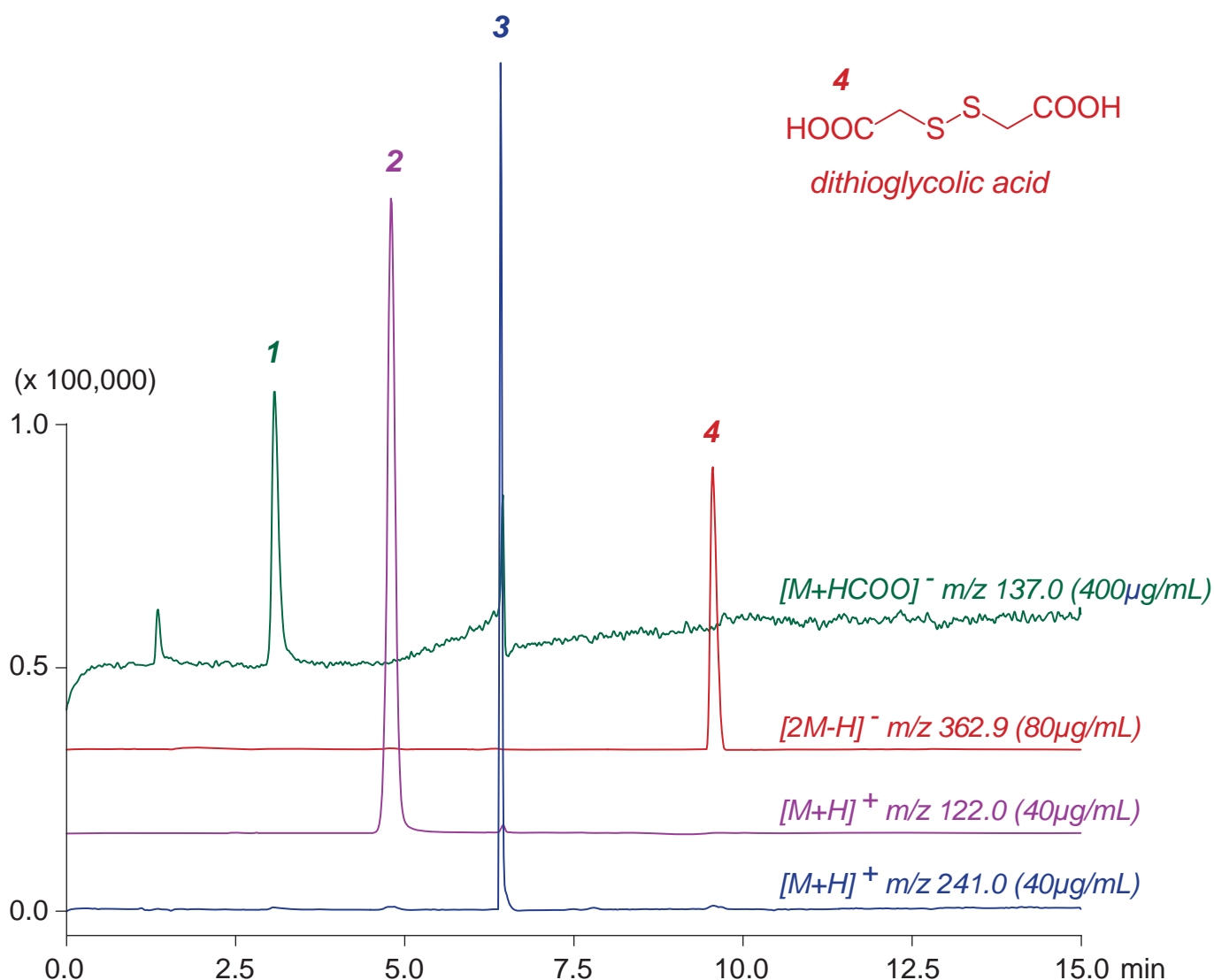
L-cysteine



L-cystine



dithioglycolic acid



Scherzo SS-C18, 100 x 3 mm

A: acetonitrile / water / formic acid = 10 / 90 / 0.1

B: acetonitrile / 100mM ammonium formate = 10 / 90

0%B (0-2min), 0-100%B (2-10min), 100%B (10-15min)

0.4mL/min (7MPa), 37°C, Single Quad. MS (ESI)

5µL (40-400µg/mL, 1% HCOOH)